

# Sha Tao

## List of Publications by Year in descending order

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Version: 2024-02-01

14  
papers

233  
citations

1040056

9  
h-index

1199594

12  
g-index

14  
all docs

14  
docs citations

14  
times ranked

200  
citing authors

#	ARTICLE	IF	CITATIONS
1	Early-stage effects of residual charges in a metal target on emitted electrons induced by femtosecond laser-metal interactions. <i>Physics Letters, Section A: General, Atomic and Solid State Physics</i> , 2017, 381, 404-407.	2.1	4
2	Amplification of Plasma at Different Initial Temperatures inside a Microhole by a Short Laser Pulse and the Effect on the Hole Sidewall. <i>Procedia Manufacturing</i> , 2016, 5, 724-733.	1.9	0
3	Modeling of picosecond laser-induced plasma amplification inside a microhole and an implied novel technology to drill microholes with varying diameters with depth. <i>Manufacturing Letters</i> , 2016, 7, 1-5.	2.2	2
4	The effect of emitted electrons during femtosecond laser-metal interactions: A physical explanation for coulomb explosion in metals. <i>Applied Surface Science</i> , 2014, 298, 90-94.	6.1	13
5	Nanosecond laser pulse interactions with breakdown plasma in gas medium confined in a microhole. <i>Applied Physics B: Lasers and Optics</i> , 2013, 113, 251-258.	2.2	12
6	The Interactions of Microhole Sidewall With Plasma induced by Femtosecond Laser Ablation in High-Aspect-Ratio Microholes. <i>Journal of Manufacturing Science and Engineering, Transactions of the ASME</i> , 2012, 134, .	2.2	5
7	Infrared long nanosecond laser pulse ablation of silicon: Integrated two-dimensional modeling and time-resolved experimental study. <i>Applied Surface Science</i> , 2012, 258, 7766-7773.	6.1	45
8	A comparative study of the interaction between microhole sidewall and the plasma generated by nanosecond and femtosecond laser ablation of deep microholes. <i>Journal of Manufacturing Processes</i> , 2012, 14, 233-242.	5.9	10
9	Study of laser beam propagation in microholes and the effect on femtosecond laser micromachining. <i>Journal of Applied Physics</i> , 2011, 109, 123506.	2.5	9
10	Physical mechanism of silicon ablation with long nanosecond laser pulses at 1064nm through time-resolved observation. <i>Applied Surface Science</i> , 2011, 257, 2886-2890.	6.1	40
11	Backward growth of plasma induced by long nanosecond laser pulse ablation. <i>Applied Physics Letters</i> , 2011, 99, 051106.	3.3	20
12	Numerical modeling of laser shock peening with femtosecond laser pulses and comparisons to experiments. <i>Applied Surface Science</i> , 2010, 256, 4376-4382.	6.1	43
13	Thermal modeling and experimental study of infrared nanosecond laser ablation of silicon. <i>Journal of Applied Physics</i> , 2009, 106, .	2.5	30
14	INFRARED NANOSECOND LASER ABLATION OF SILICON: THE SPATIAL MULTI-PULSE ENHANCEMENT EFFECT AND ITS DEPENDENCE ON LASER PULSE DURATION TECHNICAL COMMUNICATION. <i>Machining Science and Technology</i> , 2009, 13, 427-436.	2.5	0